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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Mohammed N. Islam et al.

Serial No.:

10/649,192

Filing Date:

August 27, 2003

Group Art Unit:

2872

Confirmation No.:

5256

Examiner:

John Juba, Jr.

Title:

VARIABLE BLAZED GRATING

FAX RECEIVED 6-24-04 GROUP 2870

Mail Stop Amendment Commissioner of Patents P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Information Disclosure Statement

Applicant respectfully requests, pursuant to 37 C.F.R. §§ 1.56, 1.97 and 1.98, that the references listed on the attached PTO-1449 form be considered and cited in the examination of the above-identified patent application. Copies of the references are enclosed for the convenience of the Examiner. Furthermore, pursuant to 37 C.F.R. § 1.97(h), no representation is made that these references qualify as prior art or that these references are material to the patentability of the present application.

Since the above-identified patent application was filed after June 30, 2003, a copy of any U.S. Patent and any U.S. Patent Application Publication cited on the attached PTO Form 1449 is not being submitted with this Information Disclosure Statement pursuant to the July 11, 2003 waiver of 37 C.F.R. S 1.98(a)(2)(i) by the U.S. Patent and Trademark Office.

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A check in the amount of \$280.00 is enclosed herewith to cover the cost of filing this Information Disclosure Statement. Applicant believes no other fee is due, however, the Commissioner is hereby authorized to charge any additional fee or credit any overpayment to Deposit Account No. 02-0384 of Baker Botts L.L.P.

Respectfully submitted, Baker Botts L.L.P.

Douglas M. Kubehl Attorney for Applicants Reg. No. 41,915

Correspondence Address:

X Customer Number

Date Filed: __ 6- 24-04

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